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Optical properties of ZnO and Mn-doped ZnO nanocrystals by vapor phase transport processes

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In this paper we investigated the optical properties of ZnO and Mn doped ZnO nanocrystals that were fabricated by a vapor phase transport growth process, using zinc acetate dihydrate with or without Mn in a constant O₂/Ar mixture gas flowing through the furnace at 400~600 °C, respectively. The as grown ZnO nanocrystals are homogeneous with a mean size of 19 nm observed by scanning electron microscope (SEM). The optical characteristics were analyzed by absorption spectra and photoluminescence (PL) spectra at room-temperature. For ZnO nanocrystals, a strong and predominant UV emission peaked at 377 nm was found in the PL spectra. For Mn doped ZnO nanocrystals, in addition to the strong UV emission, a strong blue emission peaked at 435 nm was observed as well. By doping Mn ions, the major UV emission shifts from 377 nm to 408 nm, showing that Mn ions were not only incorporated into ZnO Ncs, but also introduced an impurity level in the bandgap. Moreover, with the concentration of Mn increasing, the relative intensities of the two emissions change largely, and the photoluminescence mechanism of them is discussed.

Keywords: ZnO and Mn-doped ZnO nanocrystals; Optical properties; Vapor phase transport growth

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Zinc oxide (ZnO), a promising II-IV group semiconductor material with hexagonal wurtzite structure, has been widely applied in various fields [1] such as transducers, transparent conduction electrode, solar sells, and wide ultraviolet (UV) optoelectronic devices [2], due to its direct band gap of 3.37 eV at room temperature and a large exciton binding energy of 60 meV. To realize the light-emitting devices, an important issue is the fabrication of p-type conduction ZnO with a high concentration of hole and a low resistance. However, it is difficult to achieve low resistivity p-type ZnO film because of problems such as self-compensation, deep acceptor level, and low solubility of the acceptor dopants [3].

Recently, studies present that the doping of transition metal element Mn into ZnO offers a feasible mean of realizing p-type ZnO. Mn doped ZnO has also the potential to be a multifunctional material with coexisting magnetic, semi-conducting and optical properties [4], which makes a fine way to tune the bandgap in making UV detector and light emitters. Moreover, it generates a new kind of ZnO material-diluted magnetic semiconductor (DMS). Dietl et. Al [5,6] predicted that the transition temperature T_c in p-type ZnO DMS will be greater than 300 K, which is very important for making various room temperature electromagnetic devices.

Mn impurity can be incorporated into ZnO during its growth by many approaches, including pulsed laser deposition [7], hydrothermal method [8], electron spin resonanc [9], which are complicate technologies. In other researches, ZnO Ncs are grown using wet chemical methods [10,11], but the wet modality limits the device applications. In our experiment, we try to synthesize and dope ZnO nanocrystals on Si and quartz substrates by a simple vapor phase transport (VPT) process [12]. The surface morphology of the products was investigated by

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scanning electron microscope, and the optical characteristics were analyzed by photoluminescence spectra at roomtemperature. The photoluminescence mechanism for both pure ZnO nanocrystals and Mn doped ZnO are discussed as well.

ZnO nanocrystals were fabricated by a simple vapor phase transport (VPT) process, as shown in Fig. 1, where the system is consisted of a large horizontal quartz tube furnace, a vacuum system, a gas meter, and a temperature controller. Pure zinc acetate dihydrate as the source material was placed at the bottom of a one-endsealed slender quartz tube that was positioned at the center position of the furnace. For uniform growth, cleaned Si (111) and quartz wafers as the substrates were placed at end of the large tube; in front of the slender tube but far away from it. Prior to the fabrication, the furnace was pumped at vacuum and heated to 100°C and kept for 2 hours to remove the water moisture in the zinc acetate dehydrate. Then the furnace was heated to the growing temperature of 500°C. At the same time, a mixture gas of O_2 /Ar was loaded through the furnace and kept a constant flowing during the growing process. The growing process was carried out for 30 min, and the samples were taken out when the system cooled down to room temperature.



FIG. 1. Schematic diagram of the experimental system.

For Mn doped ZnO Ncs, the synthesis process is identical with above except that the source material is the mixture of zinc acetate dihydrate and manganese acetate tetrahydrate with different ratios. After the mixture decomposing at a high temperature of 500 °C, the mixed vapor of Zn/Mn was drawn out of the small tube by the flowing gas and condensed on the substrate as well. When the mixed Zn/Mn liquid droplets deposited and crystallized, ZnO Ncs were uniformly doped with Mn.

The morphology of the products was investigated by a Shimadzu SS-550 super scanning electron microscope (SEM). And the composition was analyzed by X-ray diffraction (XRD) on a RINT2000 vertical goniometer with Cu *Ka* radiation (λ =0.1541 nm). The photoluminescence (PL) measurements were performed by using a 310 nm excitation source at room temperature.

Figure 2(a) illustrates the surface morphology of ZnO Ncs on Si substrate investigated by SEM. Clearly, ZnO nanoparticles with an average size of 18 nm are uniformly dispersed on Si



FIG. 2. (a) The surface SEM image of ZnO Ncs on Si substrate; (b) the surface SEM image of ZnO Ncs on quartz substrate.



FIG. 3. The X-ray diffraction pattern of ZnO Ncs on Si substrate. The diffraction peaks corresponds the wurtzite structure of bulk ZnO.

substrate, and a few of them aggregate together, which because new small ZnO nanoparticles were nucleated continually in the growth process. At the same time, small ZnO Ncs has large surface effect than that of the bulk material, leading to the nanocrystals readily get together. Figure 2(b) is a SEM picture taken from the quartz sample, where the morphology of ZnO Ncs is similar to that of Fig. 2(a) except that the density of ZnO Ncs is lower, indicating that ZnO Ncs prefer nucleate on Si substrate to quartz. The X-ray diffraction pattern of the ZnO Ncs on Si is shown in the upper panel in Fig. 3, while the standard diffraction spectrum of the bulk wurtzite ZnO is in the down panel. We can see that the diffraction peaks and the interplane spacing are well matched to the standard diffraction pattern of wurtzite ZnO, demonstrating that our products have a distinct formation of wurtzite ZnO nanosrystals. The average diameter of ZnO DQs is 19 nm estimated from Scherrer's equation. The size is very accordance with the surface SEM image. These results indicate that the ZnO Ncs obtained in our experiment are of high quality with standard crystal shape and acceptable size.

Figure 4(a) shows an absorption spectrum of the pure ZnO Ncs on Si substrate at room temperature. It can be seen that the absorption intensity decreases sharply as the wavelength is over 355 nm, which can be defined as the absorption edge, corresponding the absorption of the intrinsic bandgap of ZnO. From the value of the absorption edge, we can estimate the bandgap of energy of ZnO Ncs to be about 3.54 eV. Figure 4(b) shows the photoluminescence (PL) spectrum of ZnO Ncs measured at room temperature. In the PL spectrum, ZnO Ncs exhibit a strong and predominant UV emission peaked at 377 nm, originating from the band to band emission of ZnO Ncs. And a much lower blue-green peak is positioned at 435 nm that is attributed to the surface defect from oxygen vacancies or zinc interstitials. For comparison, the PL spectrum of bulk ZnO is also given in a red line, where the date is magnified of 100 times. The UV and the blue emissions is absent in the bulk ZnO at room temperature, while a weak large band peaked at 500 nm (Kelly color) is appeared, attributing to the emission from the surface energy levels. Therefore, the predominant strong UV emission in ZnO Ncs results from the quantum-confined band-edge emission and the quantum size effects. Additionally, In the conventional growth methods, in order to obtain a prominent UV emission, the as grown ZnO Ncs usually require some accessional treatments, such as surface modification and annealing. In our experiment, ZnO Ncs sample achieves a very strong UV emission through a simple VPT process without any additional treatment in the experiment, showing that the as grown ZnO Ncs are of high quality.

Figure 5 shows the absorption spectrum of the Mn doped ZnO Ncs sample measured at room temperature. There are two



FIG. 5. The absorption spectrum of the Mn doped ZnO Ncs sample measured at room temperature.

absorption bands, one is located at 208 nm, and the other is a large band with a sharp absorption edge at 357 nm. The former corresponds to the absorption of MnO that has a larger band gap (4.2 eV), which makes the first absorption edge taking a blue shift. The latter is a combined absorption of ZnO:Mn Ncs, pure ZnO Ncs, and the surface defect states. Figure 6 shows the photoluminescence spectra of ZnO:Mn Ncs sample. For comparison, the PL spectrum of the pure ZnO Ncs is shown in panel (a). Figure 6(b) shows the PL spectrum of ZnO: Mn Ncs when the material ratio of Zn/Mn at 95:5. We can see that the PL property has taken a significant change by doping Mn impurity. The UV emission from the band edge of ZnO is almost quenching, replaced by two emissions with almost identical intensity in the spectrum, one is located at 409 nm, and the other is placed at 435 nm. The former can be considered as the UV emission shifting to longer wavelength of 408 nm because of Mn ions introducing an impurity in the energy





FIG. 4. (a) An absorption spectrum of the pure ZnO Ncs on Si substrate at room temperature; (b) a PL spectra of ZnO Ncs measured at room temperature, a strong and predominant UV emission peak at 377 nm originats from the band emission of ZnO Ncs. For comparison, the PL spectrum of the bulk ZnO is shown in red line that the datum is enlarged 100 times.

FIG. 6. The PL spectra of ZnO:Mn Ncs grown with different mixing ratio of Zn/Mn in source materials; (a) the PL of pure ZnO Ncs as a control spectrum; (b) the PL of ZnO:Mn with the ratio of Zn/Mn at 95:5; (c) the PL of ZnO:Mn with the ratio of Zn:Mn at 90:10.

bandgap of ZnO. The latter originates from Mn relevant compounds, such as Mn_3O_4 etc. With the ratio of Zn/Mn increase to 95:10, the blue emission of 435 nm becomes stronger, while the UV emission decreases much a lot along with shifting from 408 to 390 nm, that is, the major UV emission shifts to short wavelength again.

From the PL spectra, we know that Mn impurity is triumphantly doped into ZnO Ncs. The doping way of Mn impurity in ZnO Ncs either is an interstitial doping or a substitutional doping. If the substitutional doping occurs, Mn ion will substitute Zn ion of ZnO to form MnO. MnO has a larger band gap (4.2 eV) that may lead to the UV emission taking a blue shift in the PL spectra. However, in our experiment the UV emission shifts to longer wavelength after doping Mn, hence we deduce that the doping is more an interstitial doping than a substitutional doping. In addition, the UV emission shifts to longer wavelength initially, then back to short wavelength again. The similar phenomena also happened in other's researches on Mn doped ZnO [13,14], CdS and ZnSe. According to Bylsma's [15] second-order perturbation theory on the similar phenomena in Mn doped ZnSe bulk materials, we can give a explanation. If the doping concentration of Mn is low enough (<2%), the d orbit of Mn has strong exchange interactions with the s and p orbits of ZnO, which can be considered as a short range disorder spin system. The first interaction decreases the energy of conduction band bottom, and the second one increases the energy of valence band top, so that the band gap of the product become narrower than before, resulting in the red-shift of UV emission. With the concentration of Mn increasing (>2%), the band gap is broadening, and the emission moves back to the UV field again.

Moreover, the relative intensity ratio of the UV and the blue (435 nm) emissions changes with the ratio of Zn/Mn in the source material. With the concentration of Mn increasing, the intensity of the blue emission enhanced much a lot, which comes from surface defect levels associated with oxygen vacancies, Mn_3O_4 etc. The enhanced blue emission is mainly attributed to the increasing of Mn impurities on the surface of ZnO Ncs. Because the decomposing temperature of Mn acetate is higher than that of Zn acetate, it decomposes later than Zn acetate in the growth process. Therefore, more Mn impurities are covered on ZnO Ncs than inter-doped them, on which Mn further combines with oxygen to form Mn_3O_4 , a more stable structure, resulting in more oxygen vacancies and enhancing the green emission.

ZnO Ncs have been grown and doped with Mn by a simple technology of a vapor phase transport (VPT) process. The as grown ZnO Ncs in size of 19 nm have a distinct of wurtzite structure. Without any additional treatment, ZnO Ncs sample exhibit a strong and predominant UV emission in the PL spectra at room temperature. For Mn doped ZnO Ncs, a UV emission and a blue emission are observed, and the position of the UV emission shifts to longer wavelength direction because of Mn introduced an impurity level in the bandgap. With the concentration of Mn increasing, the blue emission enhanced much a lot due to the strong exchange interaction in the short range spin system and the excess Mn_3O_4 on the surface, respectively.

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